

IN THE CLAIMS:

Please cancel claim 1 without prejudice, and amend claims 2, 5, 11, and 14 as follows:

1. (Canceled)

2. (Currently Amended) The A magnetoresistive film according to claim 1, wherein said comprising:

a polycrystalline antiferromagnetic layer is a polycrystalline layer of a regulated having a face-centered tetragonal lattice structure;

a first pinned ferromagnetic layer superposed on the antiferromagnetic layer, a first interfacial roughness being formed between the antiferromagnetic layer and the first pinned ferromagnetic layer;

an antiferromagnetic bonding layer superposed on the first pinned ferromagnetic layer;

a second pinned ferromagnetic layer superposed on the antiferromagnetic bonding layer;

a compound existing between the antiferromagnetic bonding layer and the second pinned ferromagnetic layer, said compound including at least one of oxygen, nitrogen, sulfur and carbon combined with an element included in the antiferromagnetic bonding layer;

a non-magnetic spacer layer superposed on the second pinned ferromagnetic layer, a second interfacial roughness smaller than the first interfacial roughness being formed between the second pinned ferromagnetic layer and the non-magnetic spacer layer; and

a free ferromagnetic layer superposed on the non-magnetic spacer layer.

3. (Original) The magnetoresistive film according to claim 2, wherein said compound comprises at least one of an oxide, a nitride, a sulfide and a carbide.

4. (Cancelled)

5. (Currently Amended) The magnetoresistive film according to ~~claim~~ claim 2, wherein said antiferromagnetic bonding layer has a thickness in the range between 0.5nm and 0.9nm.

6. (Original) The magnetoresistive film according to claim 5, wherein said non-magnetic spacer layer has a thickness in the range between 1.9nm and 2.3nm.

7-10. (Cancelled)

11. (Currently Amended) A layered polycrystalline structure film comprising:

~~an~~ a polycrystalline antiferromagnetic layer having a face-centered tetragonal lattice structure;

a first crystalline ferromagnetic layer formed on the antiferromagnetic layer and having a first interfacial roughness existing between the first crystalline ferromagnetic layer and the antiferromagnetic layer;

an antiferromagnetic bonding layer formed on the first crystalline ferromagnetic layer based on epitaxy;

a second crystalline ferromagnetic layer formed on the antiferromagnetic bonding layer based on epitaxy; and

a compound existing between the antiferromagnetic bonding layer and the second crystalline ferromagnetic layer, said compound including at least one of oxygen, nitrogen, sulfur and carbon combined with an element included in the antiferromagnetic bonding layer,

wherein a second interfacial roughness smaller than the first interfacial roughness is formed between the second crystalline ferromagnetic layer and the antiferromagnetic bonding layer.

12. (Original) The layered polycrystalline structure film according to claim 11, wherein said compound comprises at least one of an oxide, a nitride, a sulfide and a carbide.

13. (Cancelled)

14. (Currently Amended) The magnetoresistive film according to ~~claim 1~~claim 2, wherein said antiferromagnetic bonding layer is a Ru layer.

15. (Previously Presented) The layered polycrystalline structure film according to claim 11, wherein said antiferromagnetic bonding layer is a Ru layer.